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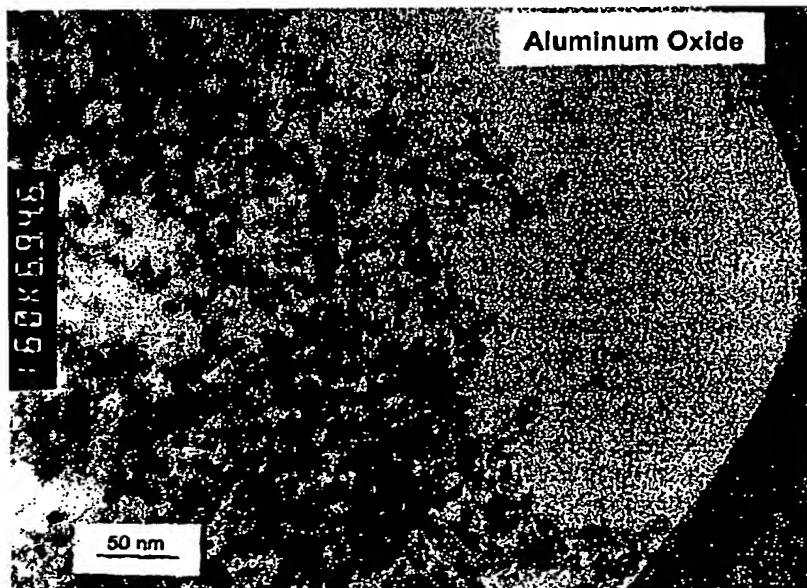
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(54) Title: ALUMINUM OXIDE PARTICLES



(57) Abstract

A collection of nanoparticles of aluminum oxide having a very narrow distribution of particle diameters are produced by laser pyrolysis. The distribution of particle diameters effectively does not have a tail and almost no particles have a diameter greater than about 4 times the average diameter. The pyrolysis is performed by pyrolyzing a molecular stream containing an aluminum precursor, an oxidizing agent and an infrared absorber.

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-1-

ALUMINUM OXIDE PARTICLES

FIELD OF THE INVENTION

The invention relates to aluminum oxide particles having small particle diameters formed by laser pyrolysis. The invention further relates to methods of producing the aluminum oxide particles based on laser pyrolysis and polishing compositions including the aluminum oxide particles.

BACKGROUND OF THE INVENTION

Technological advances have increased the demand for improved material processing with strict tolerances on processing parameters. In particular, smooth surfaces are required in a variety of applications in electronics, tool production and many other industries. The substrates requiring polishing can involve hard materials such as semiconductors, ceramics, glass and metal. As miniaturization continues even further, even more precise polishing will be required. Current submicron technology requires polishing accuracy on a nanometer scale. Precise polishing technology can employ mechanochemical polishing involving a polishing composition that acts by way of a chemical interaction of the substrate with the polishing agents as well as an abrasive effective for mechanical smoothing of the surface.

SUMMARY OF THE INVENTION

In a first aspect, the invention pertains to a collection of particles comprising aluminum oxide. The collection of particles have an average diameter from about 5 nm to about 500 nm. Also, effectively no particles have a diameter greater than about four times the average diameter of the collection of particles. A

-2-

polishing composition can be formed from a dispersion of these aluminum oxide particles.

In another aspect, the invention pertains to a polishing composition including a dispersion of
5 nanoscale aluminum oxide particles having an average diameter from about 5 nm to about 500 nm. The nanoparticles in the polishing composition preferably have effectively no particles with a diameter greater than about four times the average diameter of the
10 particles.

In another aspect, the invention pertains to a method for producing a collection of aluminum oxide particles having an average diameter from about 5 nm to about 500 nm. The method includes pyrolyzing a
15 molecular stream in a reaction chamber. The molecular stream includes an aluminum precursor, an oxidizing agent, and an infrared absorber. The pyrolysis is driven by heat absorbed from a laser beam.

In another aspect, the invention pertains to
20 a collection of particles comprising aluminum oxide, the collection of particle having an average diameter from about 5 nm to about 500 nm. The collection of aluminum oxide particles have a distribution of particle sizes such that at least about 95 percent of the particles
25 have a diameter greater than about 40 percent of the average diameter and less than about 160 percent of the average diameter.

BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a schematic sectional view of a
30 solid precursor delivery system taken through the center of the system.

Fig. 2 is a schematic, sectional view of an embodiment of a laser pyrolysis apparatus taken through the middle of the laser radiation path. The upper

-3-

insert is a bottom view of the injection nozzle, and the lower insert is a top view of the collection nozzle.

Fig. 3 is a schematic, perspective view of a reaction chamber of an alternative embodiment of the laser pyrolysis apparatus, where the materials of the chamber are depicted as transparent to reveal the interior of the apparatus.

Fig. 4 is a sectional view of the reaction chamber of Fig. 2 taken along line 3-3.

Fig. 5 is a schematic, sectional view of an oven for heating nanoparticle, in which the section is taken through the center of the quartz tube.

Fig. 6 is an x-ray diffractogram of aluminum oxide nanoparticles produced by laser pyrolysis.

Fig. 7 is a TEM micrograph of nanoparticles whose x-ray diffractogram is shown of Fig. 6.

Fig. 8 is a plot of the distribution of primary particle diameters for the nanoparticles shown in the TEM micrograph of Fig. 7.

Fig. 9 is an x-ray diffractogram of nanoparticles of aluminum oxide following heating in an oven.

Fig. 10 is a TEM micrograph of aluminum oxide nanoparticles following heat treatment in an oven.

Fig. 11 is a plot of the distribution of primary particle diameters for the nanoparticles shown in the TEM micrograph of Fig. 10.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

Aluminum oxide (Al_2O_3) particles have been produced having primary particles with extremely small average diameters and a very narrow particle size distribution. Furthermore, the particle size distribution effectively does not have a tail so that there are no primary particles with diameters

-4-

significantly larger than the average. The particles have a roughly spherical morphology, although the particles generally are crystalline and can have a more specific shape reflecting the underlying crystal
5 lattice.

Due to their extremely high uniformity in size and shape, these nanoscale aluminum oxide particles can be used to form improved abrasive compositions. Also, the aluminum oxide particles are highly pure and, in
10 particular, lack metal contaminants. Abrasive compositions incorporating these particles are useful for polishing surfaces that have restrictive tolerance requirements with respect to smoothness. The small
15 diameter of the particles along with the extremely high degree of uniformity of the particles make them particularly desirable for formulating abrasive or polishing compositions for planarization such as chemical-mechanical polishing.

To generate the desired nanoparticles, laser
20 pyrolysis is used either alone or in combination with additional processing. Specifically, laser pyrolysis is an excellent process for efficiently producing suitable aluminum oxide particles with a narrow distribution of average particle diameters. In addition, nanoscale
25 aluminum oxide particles produced by laser pyrolysis can be subjected to heating in an oxygen environment or an inert environment to alter and/or improve the properties of the particles.

A basic feature of successful application of
30 laser pyrolysis for the production of aluminum oxide nanoparticles is the generation of a molecular stream containing an aluminum precursor compound, a radiation absorber and a reactant serving as an oxygen source. The molecular stream is pyrolyzed by an intense laser

-5-

beam. As the molecular stream leaves the laser beam, the particles are rapidly quenched.

A. Particle Production

Laser pyrolysis has been discovered to be a
5 valuable tool for the production of nanoscale aluminum
oxide particles. In addition, the particles produced by
laser pyrolysis are a convenient material for further
processing to expand the pathways for the production of
desirable aluminum oxide particles. Thus, using laser
10 pyrolysis alone or in combination with additional
processes, a wide variety of aluminum oxide particles
can be produced.

The reaction conditions determine the
qualities of the particles produced by laser pyrolysis.
15 The reaction conditions for laser pyrolysis can be
controlled relatively precisely in order to produce
particles with desired properties. The appropriate
reaction conditions to produce a certain type of
particles generally depend on the design of the
20 particular apparatus. Specific conditions used to
produce aluminum oxide particles in a particular
apparatus are described below in the Examples.
Furthermore, some general observations on the
relationship between reaction conditions and the
25 resulting particles can be made.

Increasing the laser power results in
increased reaction temperatures in the reaction region
as well as a faster quenching rate. A rapid quenching
rate tends to favor production of high energy phases,
30 which may not be obtained with processes near thermal
equilibrium. Similarly, increasing the chamber pressure
also tends to favor the production of higher energy
structures. Also, increasing the concentration of the
reactant serving as the oxygen source in the reactant

-6-

stream favors the production of particles with increased amounts of oxygen.

Reactant gas flow rate and velocity of the reactant gas stream are inversely related to particle size so that increasing the reactant gas flow rate or velocity tends to result in smaller particle size. Also, the growth dynamics of the particles have a significant influence on the size of the resulting particles. In other words, different forms of a product compound have a tendency to form different size particles from other phases under relatively similar conditions. Laser power also influences particle size with increased laser power favoring larger particle formation for lower melting materials and smaller particle formation for higher melting materials.

Appropriate aluminum precursor compounds generally include aluminum compounds with reasonable vapor pressures, i.e., vapor pressures sufficient to get desired amounts of precursor vapor in the reactant stream. The vessel holding the precursor compounds can be heated to increase the vapor pressure of the aluminum precursor, if desired. Suitable liquid, aluminum precursors include, for example, aluminum s-butoxide ($\text{Al}(\text{OC}_4\text{H}_9)_3$).

A number of suitable solid, aluminum precursor compounds are available including, for example, aluminum chloride (AlCl_3), aluminum ethoxide ($\text{Al}(\text{OC}_2\text{H}_5)_3$), and aluminum isopropoxide ($\text{Al}[\text{OCH}(\text{CH}_3)_2]_3$). Solid precursors generally are heated to produce a sufficient vapor pressure. A suitable container for heating and delivering of a solid precursor to a laser pyrolysis apparatus is shown in Fig. 1.

Referring to Fig. 1, the solid precursor delivery system 50 includes a container 52 and a lid 54.

-7-

A gasket 56 is located between container 52 and lid 54. In one preferred embodiment, container 52 and lid 54 are made from stainless steel, and gasket 56 is made from copper. In this embodiment, lid 54 and gasket 56 are bolted to container 52. Other inert materials, such as Pyrex®, suitable for the temperatures and pressures applied to the solid precursor system can be used. Container 52 is surrounded with a band heater 58, which is used to set the temperature of the delivery system 50 at desired values. Suitable band heaters are available from Omega Engineering Inc. Stamford, Conn. The temperature of the band heater can be adjusted to yield a desired vapor pressure of the precursor compound. Additional portions of the precursor delivery system can be heated to maintain the precursor in a vapor state after it has left container 52.

Preferably, a thermocouple 60 is inserted into container 52 through lid 54. Thermocouple 60 can be inserted by way of a Swagelok® fitting 62 or other suitable connection. Tubing 64 provides a flow input for a carrier gas into container 52. Tubing 64 preferably includes a shut off valve 66 and can be inserted through lid 54 by way of a Swagelok® fitting 68 or other suitable connection. Output tube 70 also preferably includes a shut off valve 72. Output tube 70 preferably enters into container 52 through lid 54 at a sealed connection 74. Tubes 64 and 70 can be made of any suitable inert material such as stainless steel. A solid precursor can be placed directly within container 52 or it can be placed within a smaller, open container within container 52.

Preferred reactants serving as oxygen source include, for example, O₂, CO, CO₂, O₃ and mixtures thereof. The reactant compound from the oxygen source

-8-

should not react significantly with the aluminum precursor prior to entering the reaction zone since this generally would result in the formation of large particles.

5 Laser pyrolysis can be performed with a variety of optical laser frequencies. Preferred lasers operate in the infrared portion of the electromagnetic spectrum. CO₂ lasers are particularly preferred sources of laser light. Infrared absorbers for inclusion in the
10 molecular stream include, for example, C₂H₄, NH₃, SF₆, SiH₄ and O₃. O₃ can act as both an infrared absorber and as an oxygen source. The radiation absorber, such as the infrared absorber, absorbs energy from the radiation beam and distributes the energy to the other reactants
15 to drive the pyrolysis.

 Preferably, the energy absorbed from the radiation beam increases the temperature at a tremendous rate, many times the rate that energy generally would be produced even by strongly exothermic reactions under
20 controlled condition. While the process generally involves nonequilibrium conditions, the temperature can be described approximately based on the energy in the absorbing region. The laser pyrolysis process is qualitatively different from the process in a combustion
25 reactor where an energy source initiates a reaction, but the reaction is driven by energy given off by an exothermic reaction.

 An inert shielding gas can be used to reduce the amount of reactant and product molecules contacting
30 the reactant chamber components. Appropriate shielding gases include, for example, Ar, He and N₂.

 An appropriate laser pyrolysis apparatus generally includes a reaction chamber isolated from the ambient environment. A reactant inlet connected to a

-9-

reactant supply system produces a molecular stream through the reaction chamber. A laser beam path intersects the molecular stream at a reaction zone. The molecular stream continues after the reaction zone to an outlet, where the molecular stream exits the reaction chamber and passes into a collection system. Generally, the laser is located external to the reaction chamber, and the laser beam enters the reaction chamber through an appropriate window.

Referring to Fig. 2, a particular embodiment 100 of a pyrolysis apparatus involves a reactant supply system 102, reaction chamber 104, collection system 106 and laser 108. Reactant supply system 102 includes a source 120 of precursor compound. For liquid or solid precursors, a carrier gas from carrier gas source 122 can be introduced into precursor source 120, containing the precursor to facilitate delivery of the precursor. Precursor source 120 can be a solid precursor delivery system 50, as shown in Fig. 1. The carrier gas from source 122 preferably is either an infrared absorber or an inert gas and is preferably bubbled through a liquid, precursor compound or delivered into a solid precursor delivery system. The quantity of precursor vapor in the reaction zone is roughly proportional to the flow rate of the carrier gas.

Alternatively, carrier gas can be supplied directly from infrared absorber source 124 or inert gas source 126, as appropriate. The reactant providing the oxygen is supplied from reactant source 128, which can be a gas cylinder or other suitable container. The gases from the precursor source 120 are mixed with gases from reactant source 128, infrared absorber source 124 and inert gas source 126 by combining the gases in a single portion of tubing 130. The gases are combined a

-10-

sufficient distance from reaction chamber 104 such that the gases become well mixed prior to their entrance into reaction chamber 104. The combined gas in tube 130 passes through a duct 132 into rectangular channel 134, which forms part of an injection nozzle for directing reactants into the reaction chamber. Portions of reactant supply system 102 can be heated to inhibit the deposition of precursor compound on the walls of the delivery system. In particular, the entire chamber preferably is heated to about 140°C when aluminum chloride precursor is used. Similarly, the argon shielding gas preferably is heated to about 150°C when aluminum chloride precursor is used.

Flow from sources 122, 124, 126 and 128 are preferably independently controlled by mass flow controllers 136. Mass flow controllers 136 preferably provide a controlled flow rate from each respective source. Suitable mass flow controllers include, for example, Edwards Mass Flow Controller, Model 825 series, from Edwards High Vacuum International, Wilmington, MA.

Inert gas source 138 is connected to an inert gas duct 140, which flows into annular channel 142. A mass flow controller 144 regulates the flow of inert gas into inert gas duct 140. Inert gas source 126 can also function as the inert gas source for duct 140, if desired.

The reaction chamber 104 includes a main chamber 200. Reactant supply system 102 connects to the main chamber 200 at injection nozzle 202. The end of injection nozzle 202 has an annular opening 204 for the passage of inert shielding gas, and a rectangular slit 206 for the passage of reactant gases to form a molecular stream in the reaction chamber. Annular opening 204 has, for example, a diameter of about 1.5

-11-

inches and a width along the radial direction from about 1/8 in to about 1/16 in. The flow of shielding gas through annular opening 204 helps to prevent the spread of the reactant gases and product particles throughout reaction chamber 104. Injection nozzle 202 can be heated to keep the precursor compound in the vapor state.

Tubular sections 208, 210 are located on either side of injection nozzle 202. Tubular sections 208, 210 include ZnSe windows 212, 214, respectively. Windows 212, 214 are about 1 inch in diameter. Windows 212, 214 are preferably cylindrical lenses with a focal length equal to the distance between the center of the chamber to the surface of the lens to focus the beam to a point just below the center of the nozzle opening. Windows 212, 214 preferably have an antireflective coating. Appropriate ZnSe lenses are available from Janos Technology, Townshend, Vermont. Tubular sections 208, 210 provide for the displacement of windows 212, 214 away from main chamber 200 such that windows 212, 214 are less likely to be contaminated by reactants or products. Window 212, 214 are displaced, for example, about 3 cm from the edge of the main chamber 200.

Windows 212, 214 are sealed with a rubber o-ring to tubular sections 208, 210 to prevent the flow of ambient air into reaction chamber 104. Tubular inlets 216, 218 provide for the flow of shielding gas into tubular sections 208, 210 to reduce the contamination of windows 212, 214. Tubular inlets 216, 218 are connected to inert gas source 138 or to a separate inert gas source. In either case, flow to inlets 216, 218 preferably is controlled by a mass flow controller 220.

Laser 108 is aligned to generate a laser beam 222 that enters window 212 and exits window 214.

-12-

Windows 212, 214 define a laser light path through main chamber 200 intersecting the flow of reactants at reaction zone 224. After exiting window 214, laser beam 222 strikes power meter 226, which also acts as a beam dump. An appropriate power meter is available from Coherent Inc., Santa Clara, CA. Laser 108 can be replaced with an intense conventional light source such as an arc lamp. Preferably, laser 108 is an infrared laser, especially a CW CO₂ laser such as an 1800 watt maximum power output laser available from PRC Corp., Landing, NJ.

Reactants passing through slit 206 in injection nozzle 202 initiate a molecular stream. The molecular stream passes through reaction zone 224, where reaction involving the aluminum precursor compound takes place. Heating of the gases in reaction zone 224 is extremely rapid, roughly on the order of 10⁵ degree C/sec depending on the specific conditions. The reaction is rapidly quenched upon leaving reaction zone 224, and particles 228 are formed in the molecular stream. The nonequilibrium nature of the process allows for the production of nanoparticles with a highly uniform size distribution and structural homogeneity.

The path of the molecular stream continues to collection nozzle 230. Collection nozzle 230 is spaced about 2 cm from injection nozzle 202. The small spacing between injection nozzle 202 and collection nozzle 230 helps reduce the contamination of reaction chamber 104 with reactants and products. Collection nozzle 230 has a circular opening 232. Circular opening 232 feeds into collection system 106.

The chamber pressure is monitored with a pressure gauge attached to the main chamber. The preferred chamber pressure for the production of the

-13-

desired oxides generally ranges from about 80 Torr to about 500 Torr.

Reaction chamber 104 has two additional tubular sections not shown. One of the additional tubular sections projects into the plane of the sectional view in Fig. 2, and the second additional tubular section projects out of the plane of the sectional view in Fig. 2. When viewed from above, the four tubular sections are distributed roughly, symmetrically around the center of the chamber. These additional tubular sections have windows for observing the inside of the chamber. In this configuration of the apparatus, the two additional tubular sections are not used to facilitate production of particles.

Collection system 106 can include a curved channel 250 leading from collection nozzle 230. Because of the small size of the particles, the product particles follow the flow of the gas around curves. Collection system 106 includes a filter 252 within the gas flow to collect the product particles. A variety of materials such as Teflon, glass fibers and the like can be used for the filter as long as the material is inert and has a fine enough mesh to trap the particles. Preferred materials for the filter include, for example, a glass fiber filter from ACE Glass Inc., Vineland, NJ and cylindrical polypropylene filters from Cole-Parmer Instrument Co., Vernon Hills, IL.

Pump 254 is used to maintain collection system 106 at a selected pressure. A variety of different pumps can be used. Appropriate pumps for use as pump 254 include, for example, Busch Model B0024 pump from Busch, Inc., Virginia Beach, VA with a pumping capacity of about 25 cubic feet per minute (cfm) and Leybold Model SV300 pump from Leybold Vacuum Products, Export,

-14-

PA with a pumping capacity of about 195 cfm. It may be desirable to flow the exhaust of the pump through a scrubber 256 to remove any remaining reactive chemicals before venting into the atmosphere. The entire apparatus 100 can be placed in a fume hood for ventilation purposes and for safety considerations. Generally, the laser remains outside of the fume hood because of its large size.

The apparatus is controlled by a computer. Generally, the computer controls the laser and monitors the pressure in the reaction chamber. The computer can be used to control the flow of reactants and/or the shielding gas. The pumping rate is controlled by either a manual needle valve or an automatic throttle valve inserted between pump 254 and filter 252. As the chamber pressure increases due to the accumulation of particles on filter 252, the manual valve or the throttle valve can be adjusted to maintain the pumping rate and the corresponding chamber pressure.

The reaction can be continued until sufficient particles are collected on filter 252 such that the pump can no longer maintain the desired pressure in the reaction chamber 104 against the resistance through filter 252. When the pressure in reaction chamber 104 can no longer be maintained at the desired value, the reaction is stopped, and the filter 252 is removed. With this embodiment, about 1-90 grams of particles can be collected in a single run before the chamber pressure can no longer be maintained. A single run generally can last up to about 6 hours depending on the type of particle being produced and the type of filter being used. Therefore, it is straightforward to produce a macroscopic quantity of particles, i.e., a quantity visible with the naked eye.

-15-

The reaction conditions can be controlled relatively precisely. The mass flow controllers are quite accurate. The laser generally has about 0.5 percent power stability. With either a manual control
5 or a throttle valve, the chamber pressure can be controlled to within about 1 percent.

The configuration of the reactant supply system 102 and the collection system 106 can be reversed. In this alternative configuration, the
10 reactants are supplied from the bottom of the reaction chamber, and the product particles are collected from the top of the chamber. This alternative configuration can result in a slightly higher collection of product since aluminum oxide particles tend to be buoyant in the
15 surrounding gases. In this configuration, it is preferable to include a curved section in the collection system so that the collection filter is not mounted directly above the reaction chamber.

An alternative design of a laser pyrolysis
20 apparatus has been described. See, copending and commonly assigned U.S. Patent Application No. 08/808,850, entitled "Efficient Production of Particles by Chemical Reaction," incorporated herein by reference. This alternative design is intended to facilitate
25 production of commercial quantities of particles by laser pyrolysis. A variety of configurations are described for injecting the reactant materials into the reaction chamber.

The alternative apparatus includes a reaction
30 chamber designed to minimize contamination of the walls of the chamber with particles, to increase the production capacity and to make efficient use of resources. To accomplish these objectives, the reaction chamber conforms generally to the shape of an elongated

-16-

reactant inlet, decreasing the dead volume outside of the molecular stream. Gases can accumulate in the dead volume, increasing the amount of wasted radiation through scattering or absorption by nonreacting molecules. Also, due to reduced gas flow in the dead volume, particles can accumulate in the dead volume causing chamber contamination.

The design of the improved reaction chamber 300 is schematically shown in Figs. 3 and 4. A reactant gas channel 302 is located within block 304. Facets 306 of block 304 form a portion of conduits 308. Another portion of conduits 308 join at edge 310 with an inner surface of main chamber 312. Conduits 308 terminate at shielding gas inlets 314. Block 304 can be repositioned or replaced, depending on the reaction and desired conditions, to vary the relationship between the elongated reactant inlet 316 and shielding gas inlets 314. The shielding gases from shielding gas inlets 314 form blankets around the molecular stream originating from reactant inlet 316.

The dimensions of elongated reactant inlet 316 preferably are designed for high efficiency particle production. Reasonable dimensions for the reactant inlet for the production of the aluminum oxide particles, when used with a 1800 watt CO₂ laser, are from about 5 mm to about 1 meter.

Main chamber 312 conforms generally to the shape of elongated reactant inlet 316. Main chamber 312 includes an outlet 318 along the molecular stream for removal of particulate products, any unreacted gases and inert gases. Tubular sections 320, 322 extend from the main chamber 312. Tubular sections 320, 322 hold windows 324, 326 to define a laser beam path 328 through the reaction chamber 300. Tubular sections 320, 322 can

-17-

include shielding gas inlets 330, 332 for the introduction of shielding gas into tubular sections 320, 322.

5 The improved apparatus includes a collection system to remove the particles from the molecular stream. The collection system can be designed to collect a large quantity of particles without terminating production or, preferably, to run in continuous production by switching between different
10 particle collectors within the collection system. The collection system can include curved components within the flow path similar to curved portion of the collection system shown in Fig. 1. The configuration of the reactant injection components and the collection
15 system can be reversed such that the particles are collected at the top of the apparatus.

As noted above, properties of the product particles can be modified by further processing. In particular, aluminum oxide nanoscale particles can be
20 heated in an oven in an oxidizing environment or an inert environment to alter the oxygen content, to change the crystal lattice, or to remove adsorbed compounds on the particles to improve the quality of the particles.

The use of sufficiently mild conditions, i.e.,
25 temperatures well below the melting point of the particles, results in modification of the aluminum oxide particles without significantly sintering the particles into larger particles. The processing of metal oxide nanoscale particles in an oven is discussed in copending
30 and commonly assigned, U.S. Patent Application Ser. No. 08/897,903, filed July 21, 1997, entitled "Processing of Vanadium Oxide Particles With Heat," incorporated herein by reference.

-18-

A variety of apparatuses can be used to perform the heat processing. An example of an apparatus 400 to perform this processing is displayed in Fig. 5. Apparatus 400 includes a tube 402 into which the particles are placed. Tube 402 is connected to a reactant gas source 404 and inert gas source 406. Reactant gas, inert gas or a combination thereof are placed within tube 402 to produce the desired atmosphere.

Preferably, the desired gases are flowed through tube 402. Appropriate reactant gases to produce an oxidizing environment include, for example, O_2 , O_3 , CO, CO_2 and combinations thereof. The reactant gas can be diluted with inert gases such as Ar, He and N_2 . The gases in tube 402 can be exclusively inert gases if an inert atmosphere is desired. The reactant gases may not result in changes to the stoichiometry of the particles being heated.

Tube 402 is located within oven or furnace 408. Oven 408 maintains the relevant portions of the tube at a relatively constant temperature, although the temperature can be varied systematically through the processing step, if desired. Temperature in oven 408 generally is measured with a thermocouple 410. The aluminum oxide particles can be placed in tube 402 within a vial 412. Vial 412 prevents loss of the particles due to gas flow. Vial 412 generally is oriented with the open end directed toward the direction of the source of the gas flow.

The precise conditions including type of oxidizing gas (if any), concentration of oxidizing gas, pressure or flow rate of gas, temperature and processing time can be selected to produce the desired type of product material. The temperatures generally are mild,

-19-

i.e., significantly below the melting point of the material. The use of mild conditions avoids interparticle sintering resulting in larger particle sizes. Some controlled sintering of the particles can
5 be performed in oven 408 at somewhat higher temperatures to produce slightly larger, average particle diameters.

For the processing of aluminum oxide, for example, the temperatures preferably range from about 50°C to about 1200°C and more preferably from about 50°C
10 to about 800°C. The particles preferably are heated for about 1 hour to about 100 hours. Some empirical adjustment may be required to produce the conditions appropriate for yielding a desired material.

B. Particle Properties

15 A collection of particles of interest generally has an average diameter for the primary particles of less than about 500 nm, preferably from about 5 nm to about 100 nm, more preferably from about 5 nm to about 25 nm. The primary particles usually have
20 a roughly spherical gross appearance. Upon closer examination, the aluminum oxide particles generally have facets corresponding to the underlying crystal lattice. Nevertheless, the primary particles tend to exhibit growth that is roughly equal in the three physical
25 dimensions to give a gross spherical appearance. Generally, 95 percent of the primary particles, and preferably 99 percent, have ratios of the dimension along the major axis to the dimension along the minor axis less than about 2. Diameter measurements on
30 particles with asymmetries are based on an average of length measurements along the principle axes of the particle.

Because of their small size, the primary particles tend to form loose agglomerates due to van der

-20-

Waals and other electromagnetic forces between nearby particles. Nevertheless, the nanometer scale of the primary particles is clearly observable in transmission electron micrographs of the particles. The particles
5 generally have a surface area corresponding to particles on a nanometer scale as observed in the micrographs. Furthermore, the particles can manifest unique properties due to their small size and large surface area per weight of material. For example, TiO_2
10 nanoparticles generally exhibit altered absorption properties based on their small size, as described in copending and commonly assigned U.S. Patent Application Serial No. 08/962,515, entitled "Ultraviolet Light Block and Photocatalytic Materials," incorporated herein by
15 reference.

The primary particles preferably have a high degree of uniformity in size. As determined from examination of transmission electron micrographs, the primary particles generally have a distribution in sizes
20 such that at least about 95 percent, and preferably 99 percent, of the primary particles have a diameter greater than about 40 percent of the average diameter and less than about 160 percent of the average diameter. Preferably, the primary particles have a distribution of
25 diameters such that at least about 95 percent of the primary particles have a diameter greater than about 60 percent of the average diameter and less than about 140 percent of the average diameter.

Furthermore, essentially no primary particles
30 have an average diameter greater than about 4 times the average diameter and preferably 3 times the average diameter, and more preferably 2 times the average diameter. In other words, the particle size distribution effectively does not have a tail indicative

-21-

of a small number of particles with significantly larger sizes. This is a result of the small reaction region and corresponding rapid quench of the particles. An effective cut off in the tail indicates that there are
5 less than about 1 particle in 10^6 have a diameter greater than a particular cut off value above the average diameter. The narrow size distributions, lack of a tail in the distributions and the roughly spherical morphology can be exploited in a variety of
10 applications, especially for abrasive applications.

In addition, the nanoparticles generally have a very high purity level. The crystalline aluminum oxide nanoparticles produced by the above described methods are expected to have a purity greater than the
15 reactant gases because the crystal formation process tends to exclude contaminants from the lattice. Furthermore, crystalline aluminum oxide particles produced by laser pyrolysis have a high degree of crystallinity.

20 Aluminum oxide is known to exist in several crystalline phases including α - Al_2O_3 , δ - Al_2O_3 , γ - Al_2O_3 , ϵ - Al_2O_3 , θ - Al_2O_3 , and η - Al_2O_3 . The delta phase has a tetragonal crystal structure, and the gamma phase has a cubic crystal structure. Although under certain
25 conditions mixed phase materials are formed, laser pyrolysis generally can be used effectively to produce single phase crystalline particles. The conditions of the laser pyrolysis can be varied to favor the formation of a single, selected phase of crystalline Al_2O_3 .

30 Amorphous aluminum oxide can also be formed. Conditions favoring the formation of amorphous particles include, for example, high pressures, high flow rates, high laser power and combinations thereof.

-22-

C. Polishing Compositions

A variety of polishing compositions can advantageously incorporate nanoscale aluminum oxide particles, including compositions for performing
5 chemical-mechanical polishing. The aluminum oxide particles can function as abrasive particles. In its simplest form, the polishing composition can just involve the abrasive, aluminum oxide particles, produced as described above. More preferably, the abrasive
10 particles are dispersed in an aqueous or nonaqueous solution. The solution generally includes a solvent such as water, alcohol, acetone or the like. A surfactant can be added to add with dispersion, if desired. The abrasive particles should not be
15 significantly soluble in the solvent. The polishing composition generally includes from about 0.05 percent to about 30 percent, and preferably from about 1.0 percent to about 10 percent by weight aluminum oxide particles. The selected composition of the slurry
20 generally depends on the substrate being processed and the eventual use for that substrate. In particular, aluminum oxide particles are useful in slurries to polish metal materials including, for example, copper and tungsten wires and films.

25 Preferred polishing compositions have both a chemical and mechanical effect on a substrate. Thus, they are useful in chemical-mechanical polishing (CMP). In particular, for the polishing of semiconducting materials, oxides of semiconductor materials, or ceramic
30 substrates for the production of integrated circuits, colloidal silica can have both a chemical and/or a mechanical effect on relevant substrates. Thus, some preferred embodiments include in a solution both an

-23-

abrasive, such as aluminum oxide nanoparticles, and colloidal silica.

The formation of colloidal silica involves formation of an aqueous solution of hydrated silicon
5 oxides. The colloidal silica solution preferably includes from about 0.05 percent to about 50 percent, and preferably from about 1.0 percent to about 20 percent by weight silica. The use of colloidal silica for polishing hard substrates is described in U.S.
10 Patent No. 5,228,886, "Mechanochemical Polishing Abrasive," incorporated herein by reference, and in U.S. Patent No. 4,011,099, entitled "Preparation of Damage-Free Surface on Alpha-Alumina," incorporated herein by reference. Colloidal silica has been suggested to
15 chemically react with certain surfaces.

While conventional silica can be used to form the colloidal silica, silica particles produced by laser pyrolysis with or without additional heating are ideally suited for the production of colloidal silica. The
20 production of nanoscale silica by laser pyrolysis is described in commonly assigned and copending U.S. Patent Application 09/085,514, entitled "Silicon Oxide Particles," incorporated herein by reference.

The solvents used in the formation of the
25 polishing compositions preferably have a low level of contaminants. In particular, water used as a solvent should be deionized and/or distilled. The polishing composition preferably is free from any contaminants, i.e., any composition not included for effectuating the
30 polishing process. In particular, the polishing composition preferably is free of soluble metal contaminants such as potassium and sodium salts. Preferably, the compositions contain less than about 0.001 percent and more preferably, less than about

-24-

0.0001 percent by weight metal. Furthermore, the polishing composition preferably is free from particulate contaminants, which are not soluble in the solvent.

5 The polishing compositions can include other components to assist with the polishing process. For example, the polishing composition can include additional abrasive particles combined with the aluminum oxide. Suitable abrasive particles are described, for
10 example, in copending and commonly assigned U.S. patent application serial No. 08/961,735, entitled "Abrasive Particles for Surface Polishing," incorporated herein by reference, and in U.S. Patent 5,228,886, supra. When
15 using additional (non-aluminum oxide) abrasive particles, the polishing composition preferably includes from about 0.05 to about 10 percent additional abrasive particles.

 Suitable additional abrasive particles other than aluminum oxide particles include, for example,
20 silicon carbide, metal oxides, metal sulfides and metal carbides with average diameters less than about 100 nm and more preferably from about 5 nm to about 50 nm. In particular, preferred additional abrasive particles include compounds such as SiC, TiO₂, Fe₂O₃, Fe₃O₄, Fe₃C,
25 Fe₇C₃, MoS₂, MoO₂, WC, WO₃, and WS₂. Also, preferred abrasive particles have a relatively narrow diameter distribution and an effective cut off of particle diameters at a value that is several times larger than the average diameter.

30 The particular composition of abrasive particles should be selected such that the particles have an appropriate hardness for the surface to be polished as well as an appropriate distribution of diameters to obtain efficiently the desired smoothness.

-25-

Aluminum oxide is very hard. Thus, aluminum oxide is particularly suitable for the polishing of hard substrates. Abrasive particles that are hard can result in undesired scratches in the surface of soft
5 substrates.

The polishing composition can be acidic or basic to improve the polishing characteristics. For polishing metals an acidic pH generally is preferred, for example, in the range from about 3.0 to about 4.0.
10 A variety of acids can be used such as glacial acetic acid. For polishing oxide surfaces a basic polishing composition can be used, for example, with a pH from about 9.0 to about 11. To form a basic polishing composition, KOH or other bases can be added. Also, an
15 oxidizing agent such as H_2O_2 can be added, especially for polishing metals.

The composition of the abrasive particles should also provide for removal of the polishing compositions after completion of the polishing. One
20 approach to cleaning polished surfaces involves dissolving the abrasive particles with a cleaning solution that does not damage the polished surface. The removal of an alumina based polishing compositions using a cleaning composition with phosphoric acid is described
25 in U.S. Patent 5,389,194, entitled "Methods of Cleaning Semiconductor Substrates After Polishing," incorporated herein by reference. This patent also contains a general description of polishing with slurries containing conventional aluminum oxides.

30 The polishing compositions can be used for mechanical or chemical-mechanical polishing that is performed manually or using a powered polishing machine. In either case, the polishing composition is generally applied to a polishing pad or cloth to perform the

-26-

polishing. Any of a variety of mechanical polishers can be used, for example, vibratory polishers and rotary polishers.

The polishing compositions are particularly useful for the polishing of substrate surfaces for the production of integrated circuits. As the density of integrated circuits on a single surface increases, the tolerances for smoothness of the corresponding substrates become more stringent. Therefore, it is important that polishing process is able to remove small surface discontinuities prior to applying circuit patterns onto the substrate. The small size and uniformity of the abrasive particles disclosed herein are particularly suitable in polishing compositions for these applications. Al_2O_3 particles with or without colloidal silica are suitable for the polishing of silicon based semiconductor substrates. Similarly, layered structures involving patterned portions of insulating layers and conducting layers can be simultaneously planarized, as described in U.S. Patent No. 4,956,313, incorporated herein by reference.

EXAMPLES

Example 1 - Laser Pyrolysis for Formation of Al_2O_3 Nanoparticles

The synthesis of aluminum oxide particles described in this example was performed by laser pyrolysis. The particles were produced using essentially the laser pyrolysis apparatus of Fig. 2, described above, using the solid precursor delivery system shown schematically in Fig. 1.

The aluminum chloride (Strem Chemical, Inc., Newburyport, MA) precursor vapor was carried into the reaction chamber by flowing Ar gas through the solid precursor delivery system containing AlCl_3 . The

-27-

precursor was heated to a temperature as indicated in Table 1. C₂H₄ gas was used as a laser absorbing gas, and Argon was used as an inert gas. The reaction gas mixture containing AlCl₃, Ar, O₂ and C₂H₄ was introduced into the reactant gas nozzle for injection into the reaction chamber. The reactant gas nozzle had an opening with dimensions of 5/8 in. x 1/8 in. Additional parameters of the laser pyrolysis synthesis relating to the particles of Example 1 are specified in Table 1.

TABLE 1

Sample	1
Crystal Structure	γ -Al ₂ O ₃ (cubic)
Pressure (Torr)	120
Argon - Win. (sccm)	700
Argon - Sld. (slm)	2.8
Ethylene (sccm)	725
Carrier Gas (sccm)	705 (Ar)
Oxygen (sccm)	552
Laser Output (watts)	600
Precursor Temperature (°C)	260

sccm = standard cubic centimeters per minute

slm = standard liters per minute

Argon - Win. = argon flow through inlets 216, 218

Argon - Sld. = argon flow through annular channel 142.

-28-

The production rate of aluminum oxide particles was typically about 4 g/hr. To evaluate the atomic arrangement, the samples were examined by x-ray diffraction using the Cu(K α) radiation line on a Siemens
5 D500 x-ray diffractometer. An x-ray diffractogram for a sample produced under the conditions specified in Table 1 is shown in Fig. 6. Under the set of conditions specified in Table 1, the particles had an x-ray diffractogram corresponding to γ -Al₂O₃ (cubic) although
10 the diffractogram contained a considerable amount of noise.

Transmission electron microscopy (TEM) was used to determine particle sizes and morphology. A TEM micrograph for the particles produced under the
15 conditions of Table 1 is displayed in Fig. 7. An examination of a portion of the TEM micrograph yielded an average particle size of about 7 nm. The corresponding particle size distribution is shown in Fig. 8. The approximate size distribution was
20 determined by manually measuring diameters of the particles distinctly visible in the micrograph of Fig. 7. Only those particles having clear particle boundaries were measured to avoid regions distorted or out of focus in the micrograph. Measurements so
25 obtained should be more accurate and are not biased

-29-

since a single view cannot show a clear view of all particles. It is significant that the particles span a rather narrow range of sizes.

The particles produced by laser pyrolysis had
5 a dark color, evidently due to the presence of carbon associated with the particles. The carbon can come from the ethylene used as the laser absorbing gas. The dark color was removed by heating as described in Example 2. The production of carbon coated nanoparticles is
10 described further in copending and commonly assigned patent application Serial No. 09/123,255, entitled "Metal (Silicon) Oxide/Carbon Composite Particles," filed on July 22, 1998, incorporated herein by reference.

15 Example 2 - Oven Processed

A sample of aluminum oxide nanoparticles produced by laser pyrolysis according to the conditions specified in Table 1 were heated in an oven under oxidizing conditions. The oven was essentially as
20 described above with respect to Fig. 5. The samples were heated in the oven at about 500°C for about 2 hours. Oxygen gas was flowed through a 1.0 in diameter quartz tube at a flow rate of about 250 sccm. Between about 100 and about 300 mg of nanoparticles were placed
25 in an open 1 cc vial within the quartz tube projecting

-30-

through the oven. After heating, the particles had a white color. The resulting particles were γ - Al_2O_3 , as determined by x-ray diffraction. The x-ray diffractogram is shown in Fig. 9. The diffractogram in Fig. 9 has a higher signal-to-noise ratio than the diffractogram in Fig. 6. This improvement in signal-to-noise may be due to an increased level of crystallinity.

A TEM micrograph for the heat treated Al_2O_3 nanoparticles is shown in Fig. 10. The corresponding particle size distribution is shown in Fig. 11. The particle size distribution was produced following the same procedures as used to produce the distribution in Fig. 8.

15 Example 3 - Slurries of Aluminum Oxide Nanoparticles

This example includes a description of the preparation of a slurry with about 1 percent by weight aluminum oxide nanoparticles.

A 5 ml quantity of deionized water was placed in a Waring® blender. The blender was set on a slow setting, and 0.1000g of Al_2O_3 nanoparticles made by laser pyrolysis was added to the blender. Following addition of the dry powder, 2 ml of deionized water was added as a rinse. The pH of the concentrated slurry was adjusted by the addition of 0.2 ml of approximately 2

-31-

percent by weight HCl. After addition of the HCl, the blender speed setting was increased to medium-high for 30 seconds and then lowered again to the slow setting. The concentrated slurry was diluted with enough water to form 10 ml total liquid content. After the addition of the additional water, the blender speed was again increased to medium-high for 30 seconds. Then, the mixer was stopped. The pH of the resulting slurry was about 3. The resulting slurry had a color that was either milky if heat treated samples were used, or a coffee color if particles that were not heat treated were used. The slurries were each placed in a sealed bottle.

The embodiments described above are intended to be representative and not limiting. Additional embodiments of the invention are within the claims. Although the present invention has been described with reference to preferred embodiments, workers skilled in the art will recognize that changes may be made in form and detail without departing from the spirit and scope of the invention.

-32-

WHAT IS CLAIMED IS:

1. A collection of particles comprising aluminum oxide, the collection of particle having an average diameter from about 5 nm to about 500 nm and effectively no particles have a diameter greater than about four times the average diameter of the collection of particles.
2. The collection of particles of claim 1 wherein the collection of particles have an average diameter from about 5 nm to about 25 nm.
3. The collection of particles of claim 1 wherein the aluminum oxide has a crystalline structure of γ - Al_2O_3 .
4. The collection of particles of claim 1 wherein the collection of particles includes effectively no particles with a diameter greater than about three times the average diameter.
5. The collection of particles of claim 1 wherein the collection of particles includes effectively no particles with a diameter greater than about two times the average diameter.
6. The collection of particles of claim 1 wherein the collection of particles have a distribution of particle sizes such that at least about 95 percent of the particles have a diameter greater than about 40

-33-

percent of the average diameter and less than about 160 percent of the average diameter.

7. The collection of particles of claim 1 wherein the collection of particles have a distribution of particle sizes such that at least about 95 percent of the particles have a diameter greater than about 60 percent of the average diameter and less than about 140 percent of the average diameter.

8. The collection of particles of claim 1 wherein the collection of particles have a distribution of particle sizes such that at least about 99 percent of the particles have a diameter greater than about 40 percent of the average diameter and less than about 160 percent of the average diameter.

9. A polishing composition comprising a dispersion of aluminum oxide particles of claim 1.

10. The polishing composition of claim 9 wherein the aluminum oxide has a crystalline structure of γ - Al_2O_3 .

11. The polishing composition of claim 9 wherein the polishing composition comprises from about 0.05 percent by weight to about 15 percent by weight aluminum oxide particles.

12. The polishing composition of claim 9 wherein the polishing composition comprises from about 1.0

-34-

percent by weight to about 10 percent by weight aluminum oxide particles.

13. The polishing composition of claim 9 wherein the dispersion is an aqueous dispersion.

14. The polishing composition of claim 9 wherein the dispersion is a nonaqueous dispersion.

15. The polishing composition of claim 9 further comprising abrasive particles comprising a composition selected from the group consisting of silicon carbide, metal oxides other than aluminum oxide, metal sulfides and metal carbides.

16. The polishing composition of claim 9 further comprising colloidal silica.

17. A method for producing a collection of aluminum oxide particles having an average diameter from about 5 nm to about 500 nm, the method comprising pyrolyzing a molecular stream in a reaction chamber, the molecular stream comprising an aluminum precursor, an oxidizing agent, and an infrared absorber, where the pyrolysis is driven by heat absorbed from a laser beam.

18. The method of claim 16 wherein the aluminum oxide particles have an average diameter from about 5 nm to about 100 nm.

19. A collection of particles comprising aluminum oxide, the collection of particles having an average

-35-

diameter from about 5 nm to about 500 nm and a distribution of particle sizes such that at least about 95 percent of the particles have a diameter greater than about 40 percent of the average diameter and less than about 160 percent of the average diameter.

20. The collection of particles of claim 19 wherein the aluminum oxide has a crystalline structure of $\gamma\text{-Al}_2\text{O}_3$.

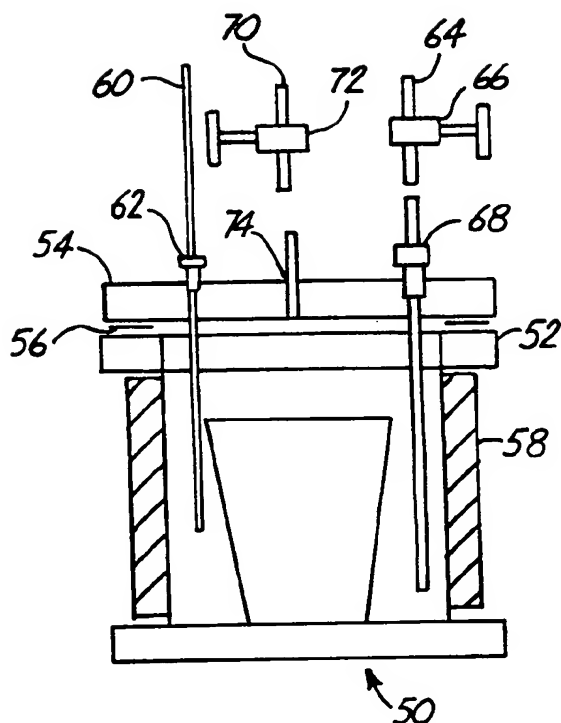


Fig. 1

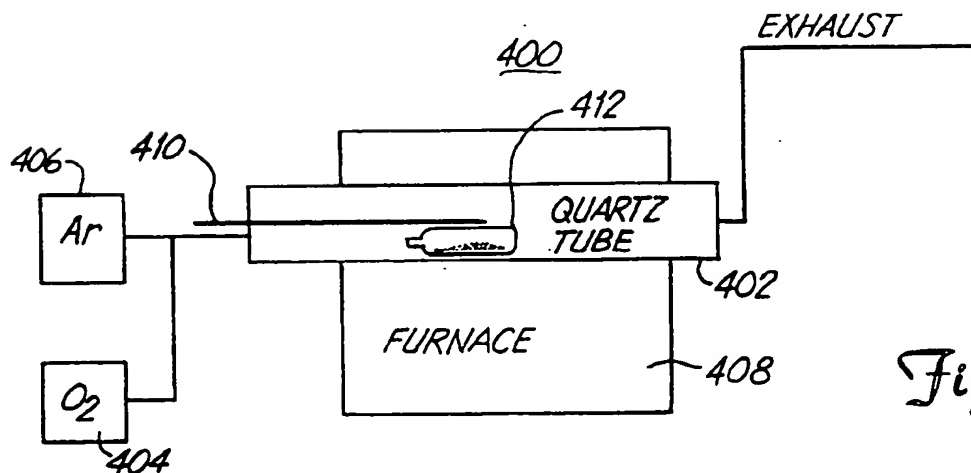


Fig. 5

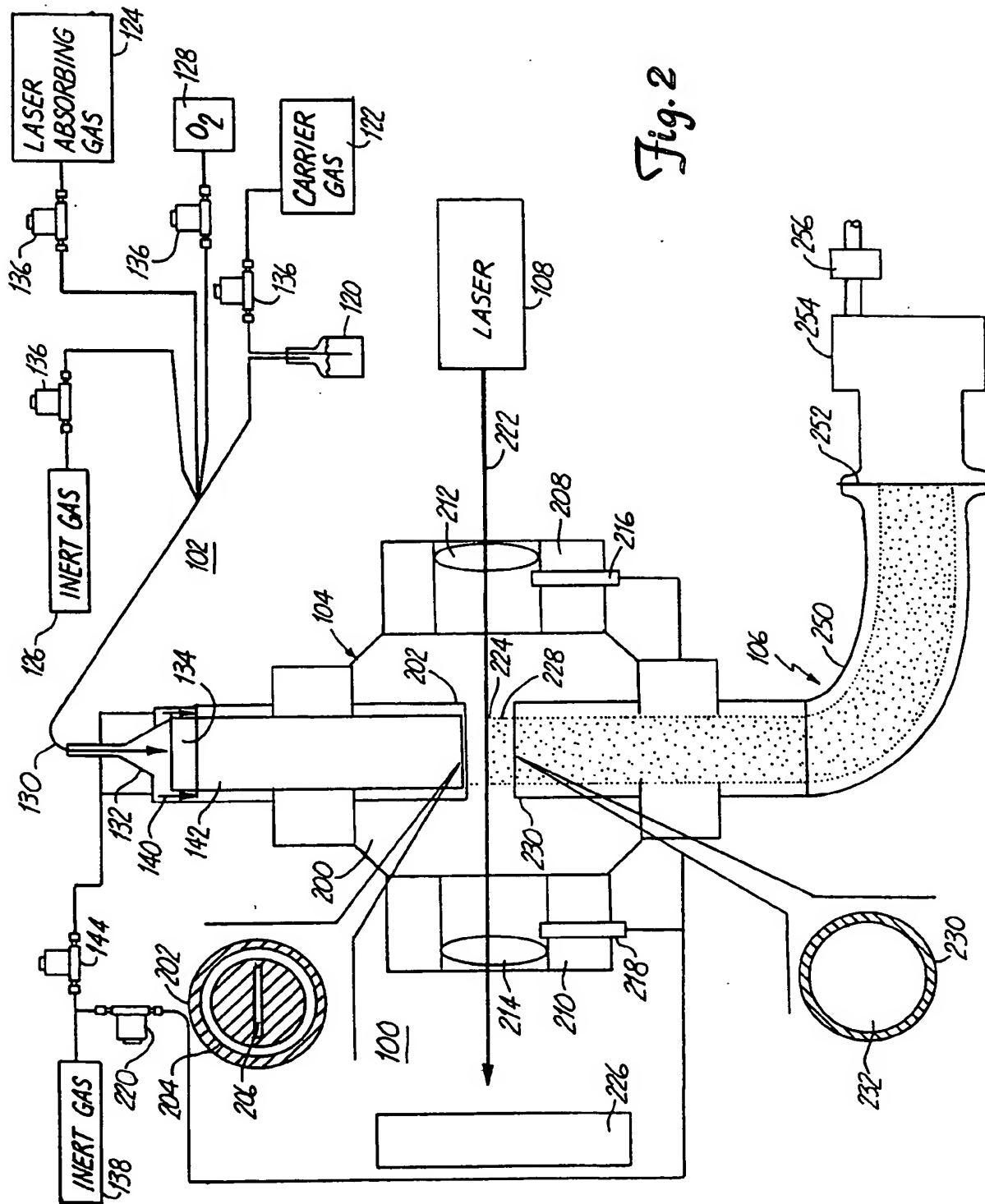
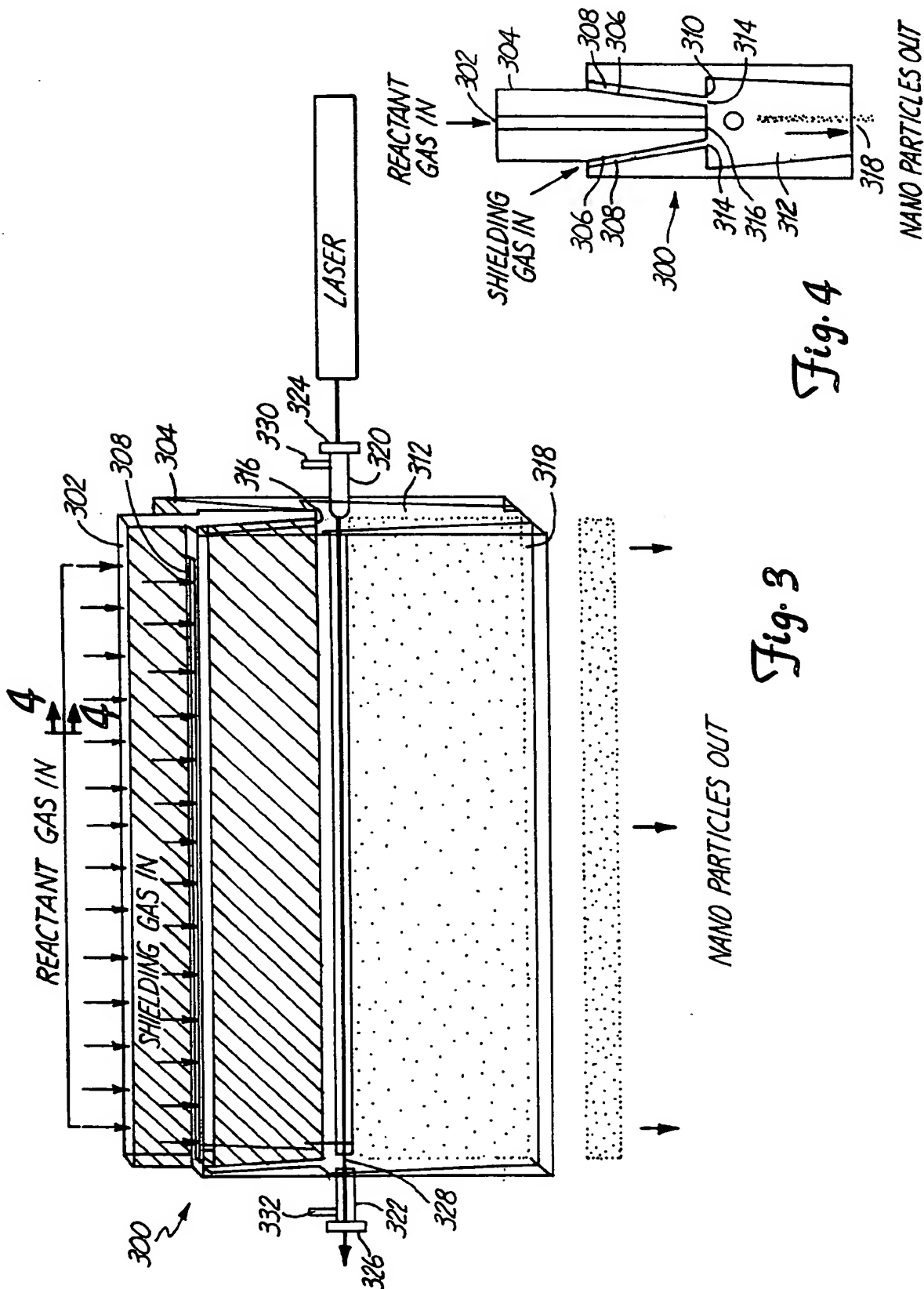


Fig. 2



Aluminum Oxide

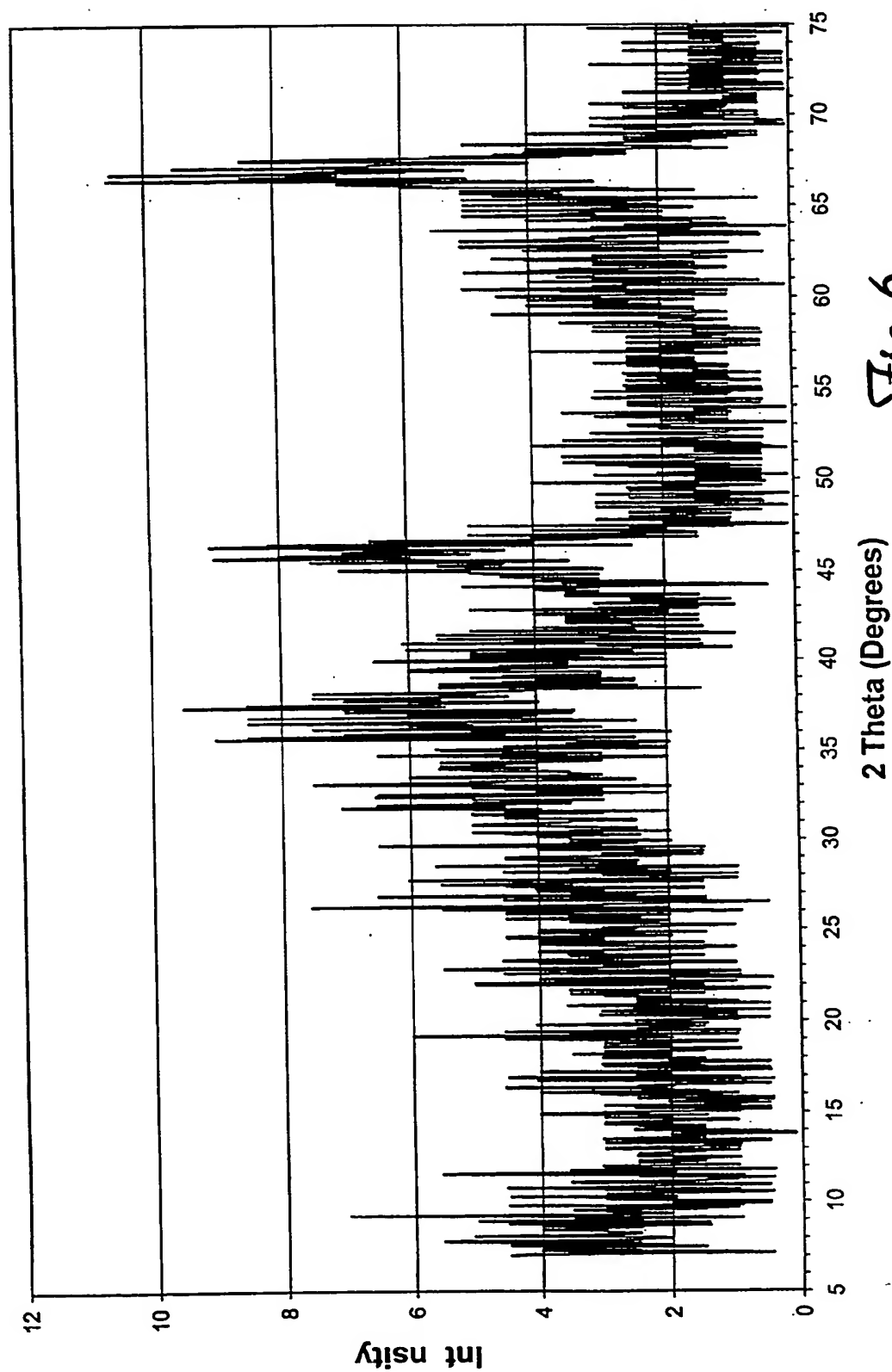


Fig. 6

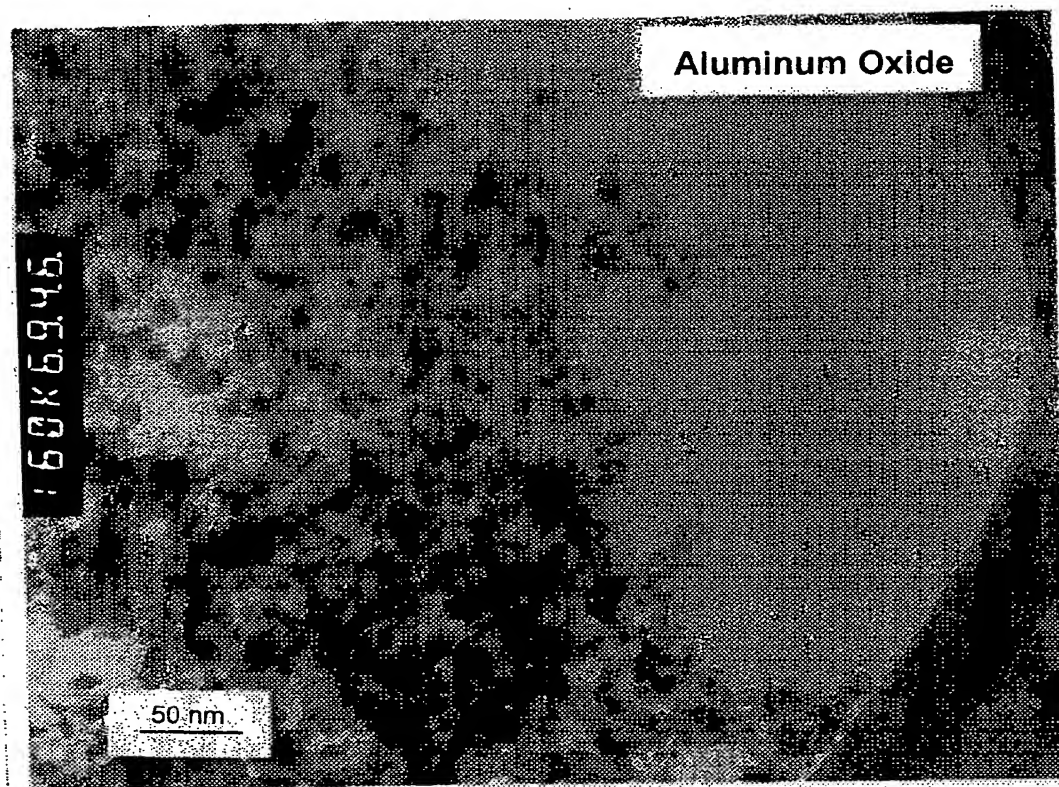
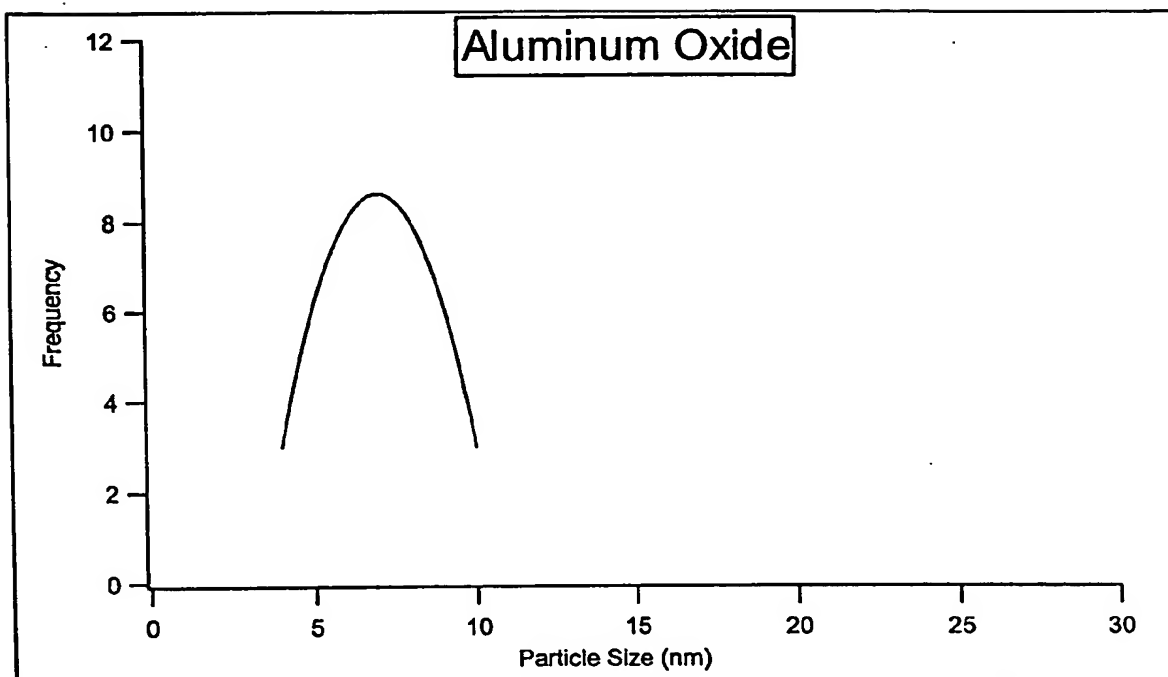
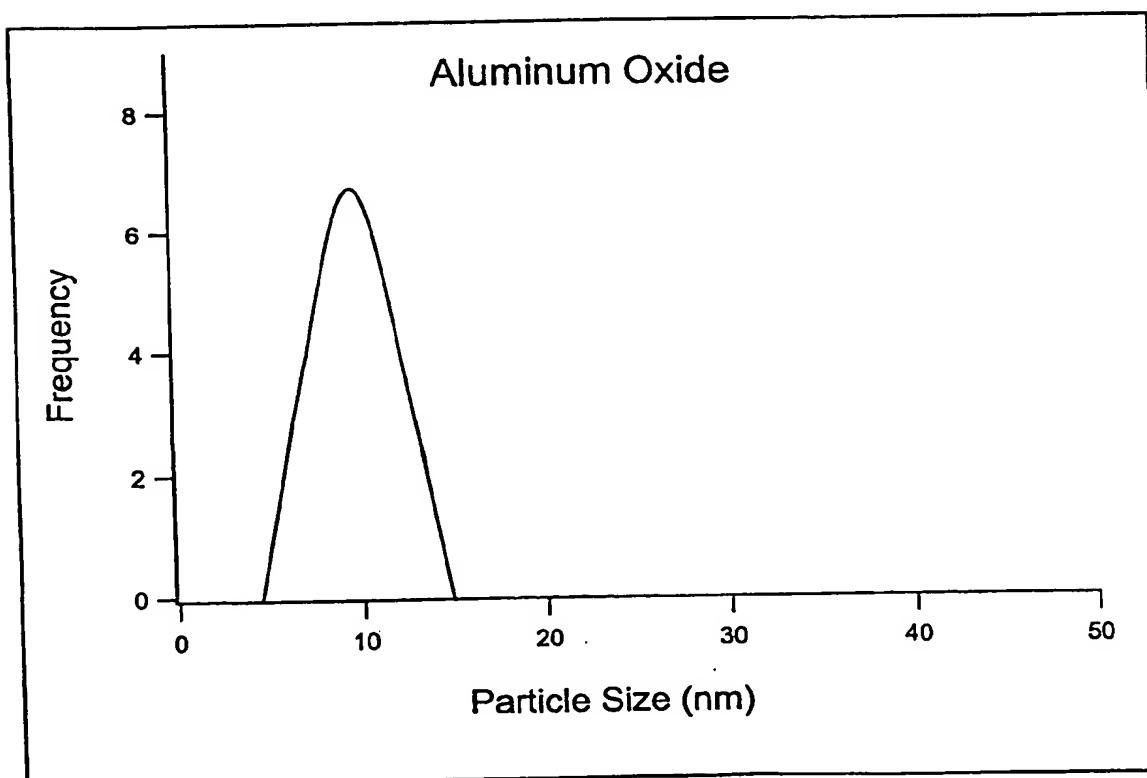


Fig. 7

*Fig. 8**Fig. 11*

Aluminum Oxide

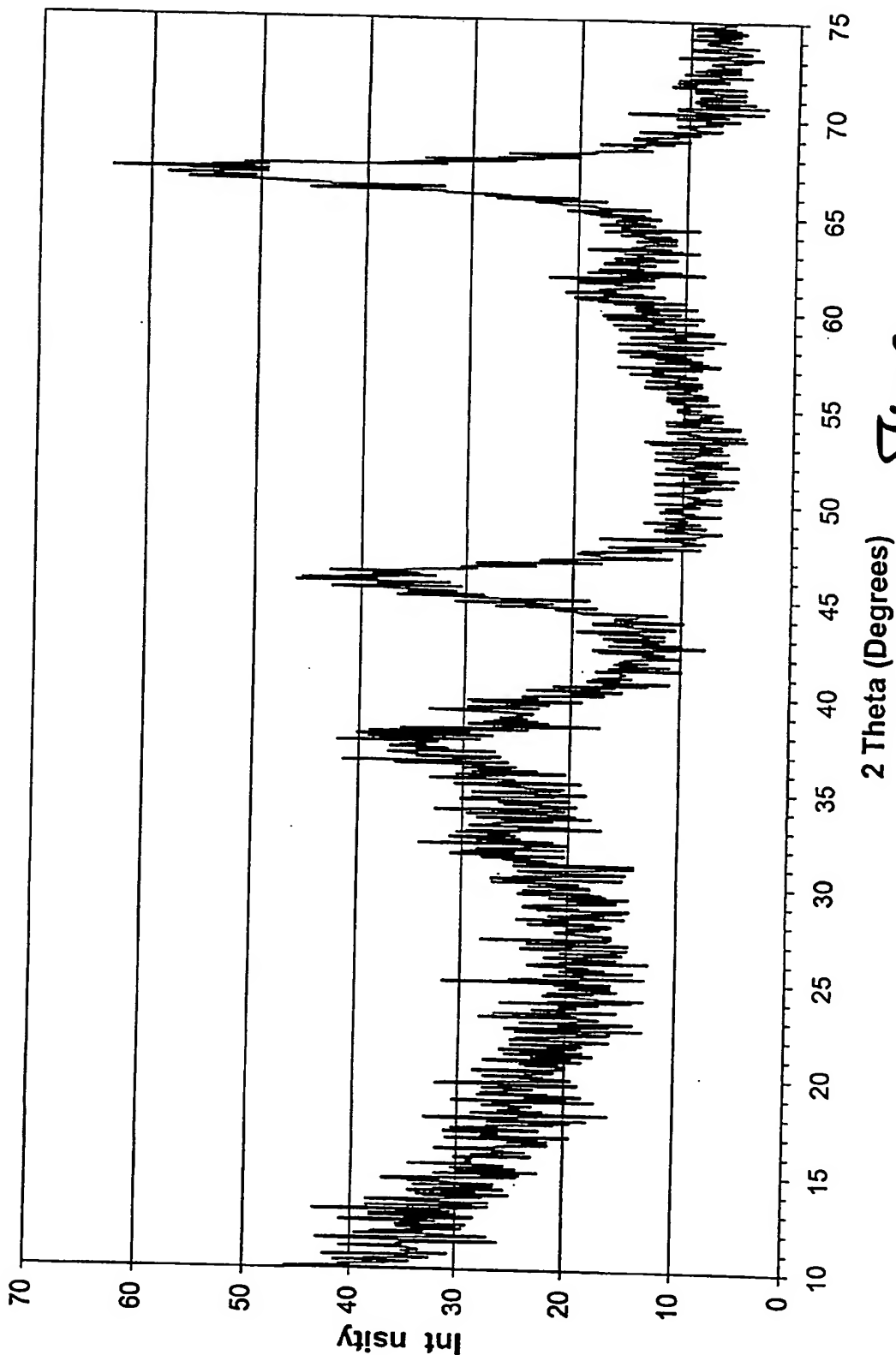


Fig. 9

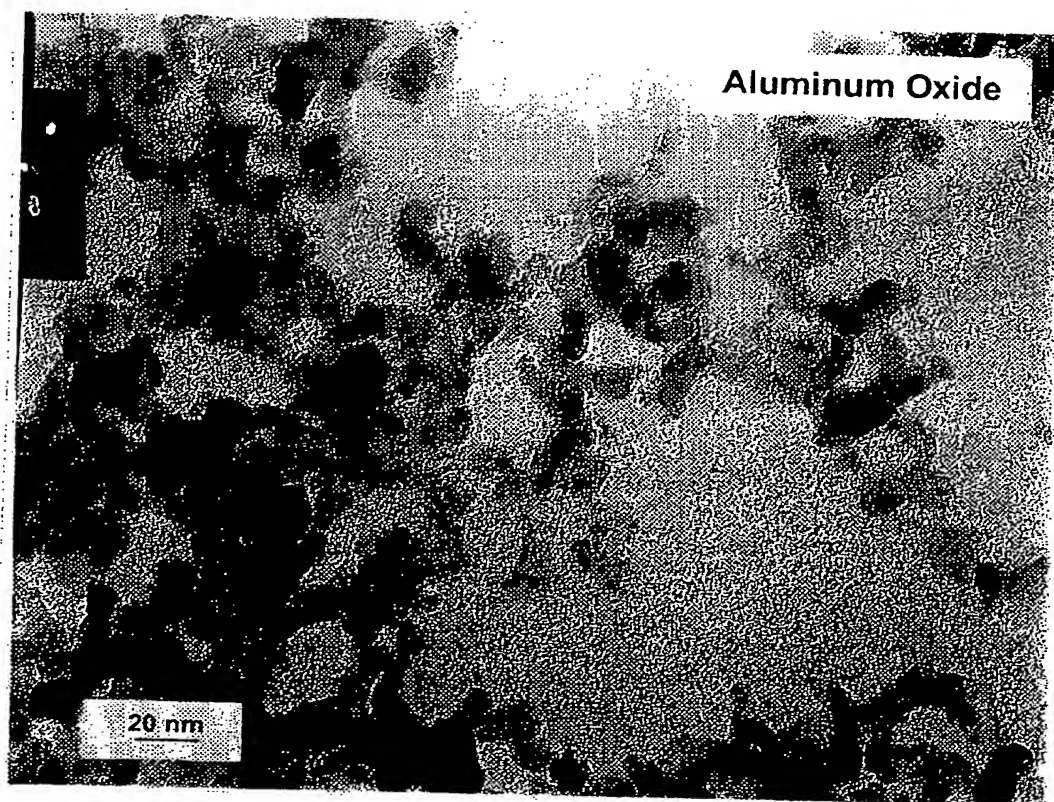


Fig. 10

INTERNATIONAL SEARCH REPORT

International application No.
PCT/US99/18169

A. CLASSIFICATION OF SUBJECT MATTER

IPC(6) :C01G 1/02; B24D3/00; C01B13/00; C01F7/02
US CL :51/309; 106/3; 438/692,693; 451/36; 204/157.41,157.51; 423/625
According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

U.S. : 51/309; 106/3; 438/692,693; 451/36; 204/157.41,157.51; 423/625

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched
NONE

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)
NONE

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 4,861,572 A (SUGOH et al.) 29 August 1989 (29/08/89), see the claims.	1-20
Y	US 4,705,762 A (OTA et al.) 10 November 1987 (10/11/87), see the abstract and the claims.	1-20
Y	US 5,635,154 A (ARAI et al.) 03 June 1997 (03/06/97), see the claims.	1-20
Y	US 5,417,956 A (MOSER) 23 May 1995 (23/05/95), see the abstract and the claims.	1-20
Y	US 5,447,708 A (HELBLE et al.) 05 September 1995 (05/09/95), see the claims.	1-20
Y	US 5,697,992 A (UEDA et al.) 16 December 1997 (16/12/97), see the abstract and the claims.	1-20

☒ Further documents are listed in the continuation of Box C. ☐ See patent family annex.

* Special categories of cited documents:	*T* later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
A document defining the general state of the art which is not considered to be of particular relevance	*X* document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
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L document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	*A* document member of the same patent family
O document referring to an oral disclosure, use, exhibition or other means	
P document published prior to the international filing date but later than the priority date claimed	

Date of the actual completion of the international search
05 NOVEMBER 1999

Date of mailing of the international search report
19 NOV 1999

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INTERNATIONAL SEARCH REPORT

International application No.
PCT/US99/18169

C (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 4,021,263 A (ROSENBLUM) 03 May 1977 (03/05/77), see the abstract and the claims.	1-20
Y	US 5,228,886 A (ZIPPERIAN) 20 July 1993 (20/07/93), see the claims.	1-20
Y	US 5,389,194 A (ROSTOKER et al.) 14 February 1995 (14/02/95), see entire document.	1-20
Y	US 5,300,130 A (ROSTOKER) 05 April 1994 (05/04/94), see the abstract and the claims.	1-20
Y	US 5,693,239 A (WANG et al.) 02 December 1997 (02/12/97), see the abstract and the claims.	1-20
Y	US 5,527,423 A (NEVILLE et al.) 18 June 1996 (18/06/96), see the claims.	1-20
Y	US 5,064,517 A (SHIMO) 12 November 1991 (12/11/91), see entire document.	17-18